

Application No.: 10/612184
Docket No.: HP0070USNA

Page 5

REMARKS

Applicants respectfully request favorable reconsideration for the following reasons:

1. The original numbering of the claims has been preserved and properly corrected in accordance with the Examiner's comments.
2. Regarding 35 U.S.C. Sections 102(e) and 103(a):
 - a. Claims 1 and 2 have been combined and the resistivity ranges have been narrowed, thereby limiting the present invention to a particular type of oriented film (or precursor thereto) having a volume resistivity at least an order of magnitude greater than the surface resistivity;
 - b. neither Chacko (USP 6,617,377) nor Schlueter et al. (USP 6,201,945) disclose a film drawing (stretching) technology to modify resistivities in this manner; and
 - c. the amended claims are now directed to a particular type of film (or precursor thereto) having improved (advantageous) electrostatic dissipation properties, where an applied charge will preferentially dissipate at the surface (in contradistinction to permeating through the volume).

Application No.: 10/612184
Docket No.: HP0070USNA

Page 6

In view of the foregoing, allowance of the above-referenced application is respectfully requested.

Respectfully submitted,



KONRAD KAEDING
ATTORNEY FOR APPLICANTS
Registration No.: 32,035
Telephone: (302) 992-2093
Facsimile: (302) 892-7949

Dated: July 6, 2005